



TW
AF

THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of : **Confirmation No. 1092**
Hiroto YUKAWA et al. : Attorney Docket No. 2004_0499
Serial No. 10/810,902 : Group Art Unit 1752
Filed March 29, 2004 : Examiner Sin J. Lee
POSITIVE-WORKING CHEMICAL- : Mail Stop: AF
AMPLIFICATION PHOTORESIST
COMPOSITION

RESPONSE TO FINAL REJECTION

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In Response to the Final Rejection dated July 12, 2006, please amend the present application as follows:

Please
Enter
S.J.L.
9/11/06